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Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

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- 1. (currently amended) A method of building a <u>wafer</u> defect database, the <u>wafer</u> defect database comprising a defect classification recipe which is used for a defect classification machine to perform an automatic defect classification, the method of building the defect database comprising following steps:
 - (a) providing a <u>first</u> wafer with a plurality of defects thereon that were generated during a <u>first</u> semiconductor process;
 - (b) performing a defect inspection to the first wafer to detect detect the defects;
 - (c) providing a <u>predetermined</u> defect database which comprises a defect classification recipe corresponding to a second semiconductor process;
 - (d) <u>utilizing the defect classification machine to perform performing</u> an automatic defect classification according to the defect classification recipe <u>predetermined</u> <u>defect database</u> to separate the defects into a plurality of defect types;
 - (e) performing a manual defect classification to verify the accuracy of the automatic defect classification to each defect type; to separate the defects into a plurality of defect types; and
- 20 performing a verifying stop to verify accuracy of the automatic defect classification foreach defect type.
 - (f) assigning the predetermined defect database as the wafer defect database when the accuracy of the automatic defect classification is qualified and setting up the predetermined database for online usage;
- 25 (g) performing an updating step to correct the predetermined defect database when the accuracy of a specific defect type of the automatic defect classification is not qualified, wherein the updating step comprises:
 - providing a second wafer with a plurality of defects, wherein the second wafer

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was generated from the first semiconductor process;

performing a defect inspection to the second wafer; and

collecting defect classification recipe of the specific defect type to correct the

defect classification recipe within the predetermined defect database; and

(h) repeating steps (d), (e), (f), and (g) to complete the wafer defect database.

- 2. (cancelled)
- 10 3. (cancelled)

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- 4. (original) The method of claim 1 wherein the second semiconductor process is a previous generation process compared to the first semiconductor process with the same design rule.
- 5. (original) The method of claim 1 wherein the first semiconductor process and the second semiconductor process have similar patterns or defect types.
- 6. (currently amended) A method of an automatic wafer defect classification comprising:
 providing a wafer with a plurality of defects thereon that were generated during a first
 semiconductor process;

performing a defect inspection to detect the defects;

providing a defect database which comprises a defect classification recipe

corresponding to a second semiconductor process; and

performing an automatic defect classification according to the defect recipe to separate

- 25 the defects into a plurality of defect types.
 - 7. (currently amended) The method of claim 6 further comprising a verifying step to verify accuracy of the automatic defect classification for each defect type, the verifying step

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comprising:

performing a manual defect classification to the defect; and
utilizing the result from the manual defect classification to verify the accuracy of the
automatic defect classification.

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- 8. (cancelled)
- 9. (currently amended) The method of claim 7 further comprising a step of updating the defect database if the accuracy of the automatic defect classification is not qualified, the step
- 10 <u>comprising:</u>

with unqualified accuracy according to the result of the manual defect classification;

correcting the defect database according to the defect information; and

repeating the verifying step.

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- 10. (cancelled)
- 11. (original) The method of claim 6 wherein the second semiconductor process is a previous generation process compared to the first semiconductor process with the same design rule.

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12. (original) The method of claim 6 wherein the first semiconductor process and the second semiconductor process have similar patterns or defect types.

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